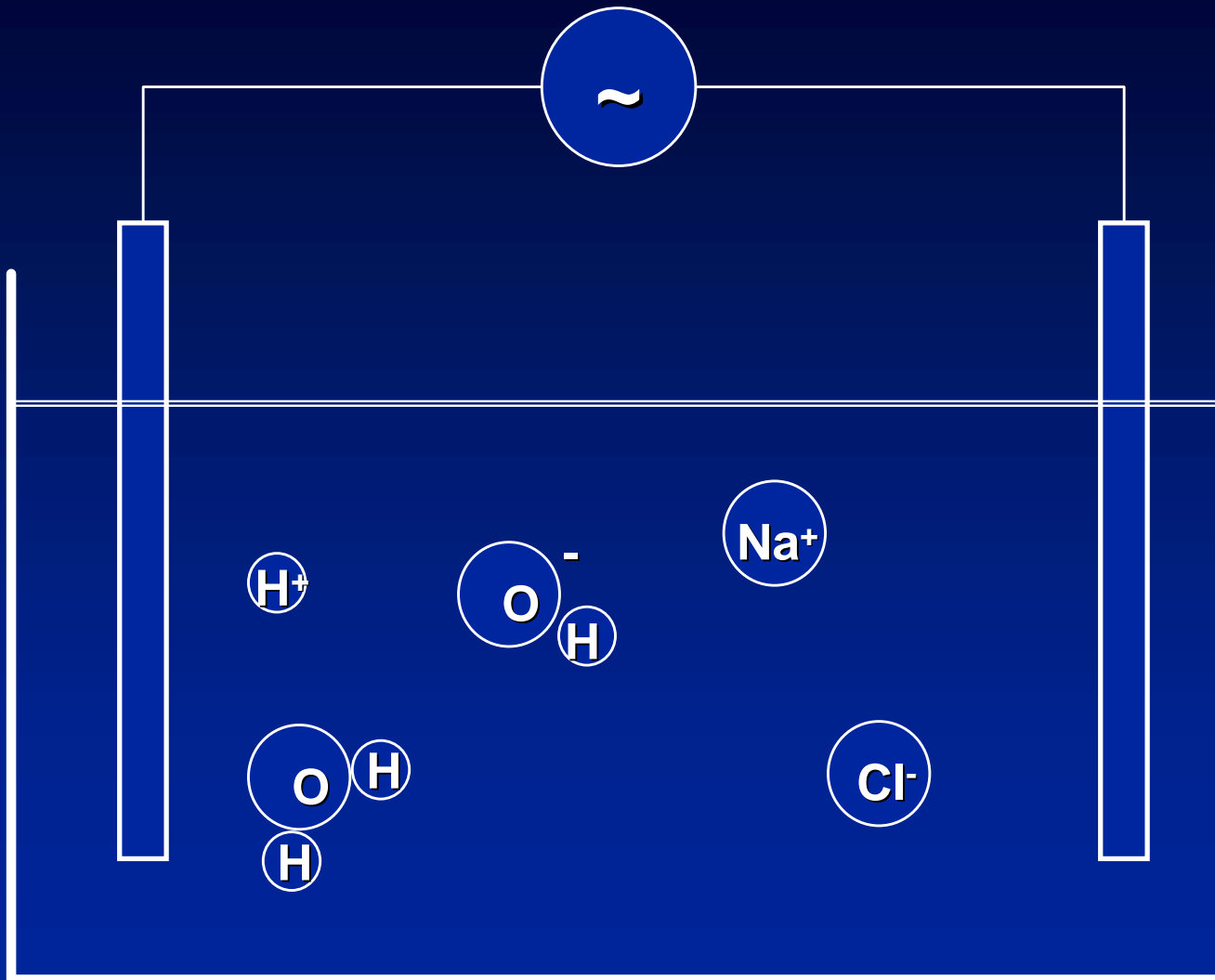




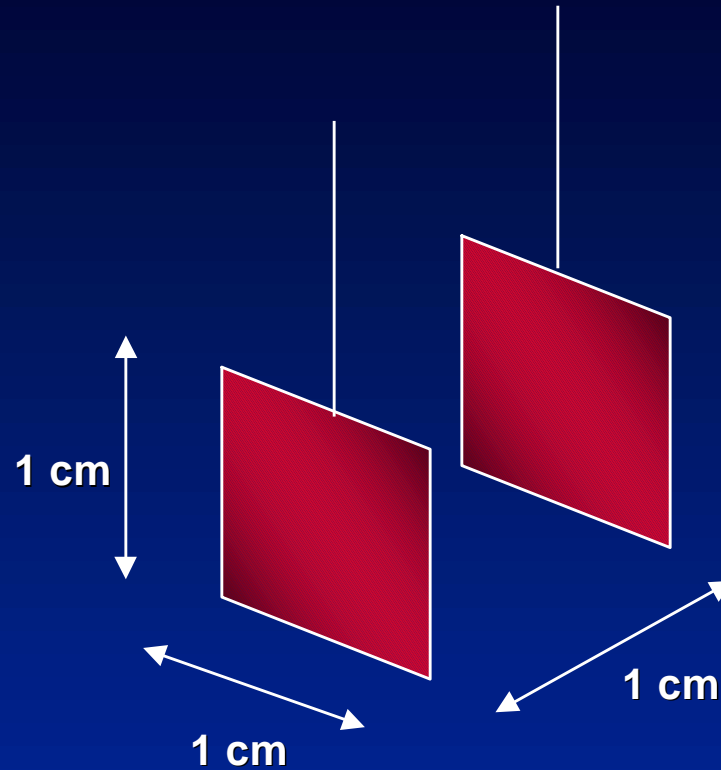
Theory of Liquid Measurements

- *Conductivity/Resistivity*
- *pH*
- *ORP*

Ionic Conductance

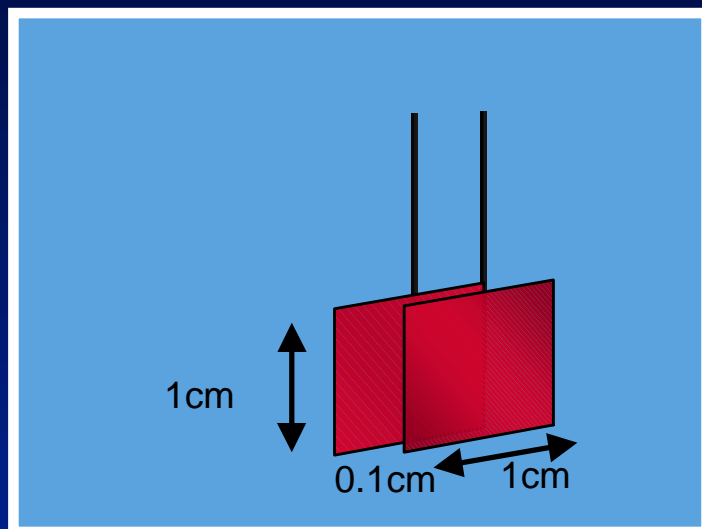


Cell Constant

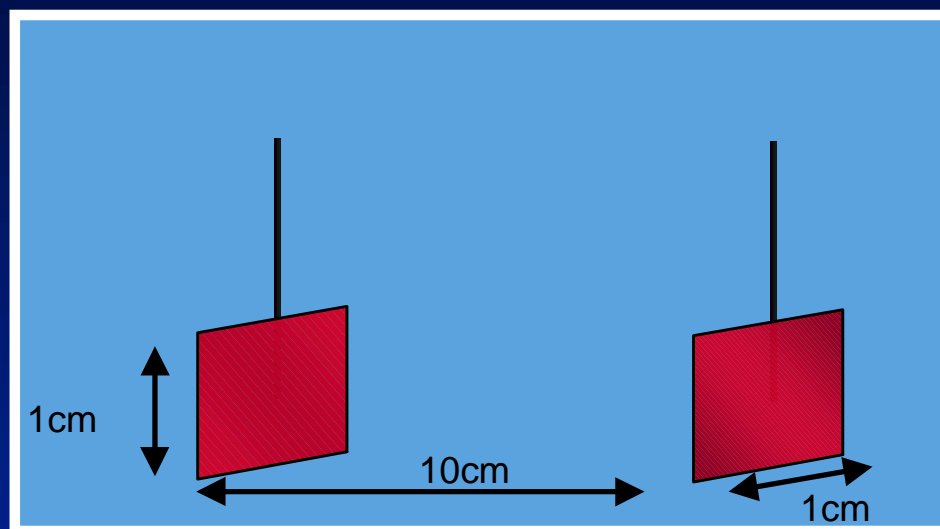


$$\text{Conductivity Cell Constant} = \frac{\text{Length}}{\text{Area}} = \frac{1 \text{ cm}}{1 \text{ cm}^2} = 1 \text{ cm}^{-1}$$

Other Cell Constants



0.1 constant

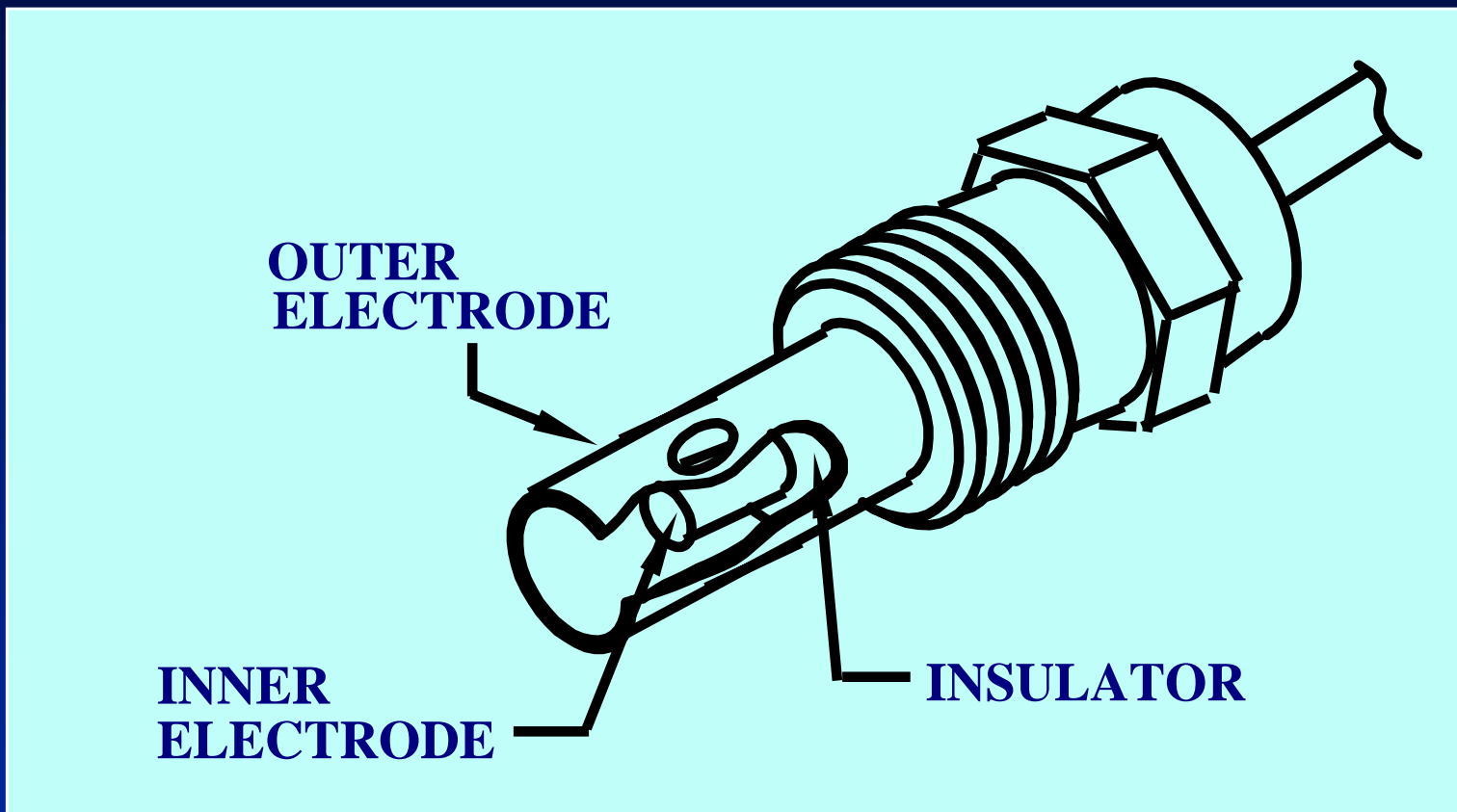


10.0 constant

Cell Constant = Multiplier

Resistivity/Conductivity Cell

Concentric Electrodes





Units of Conductivity/Resistivity

Resistance

ohm

Conductance

mho, siemens = 1/ohm

Resistivity

**ohm-cm,
megohm-cm, MΩ-cm**

Conductivity

**mho/cm,
μmho/cm
siemens/cm,
microsiemens/cm, μS/cm**

Units of Conductivity/Resistivity

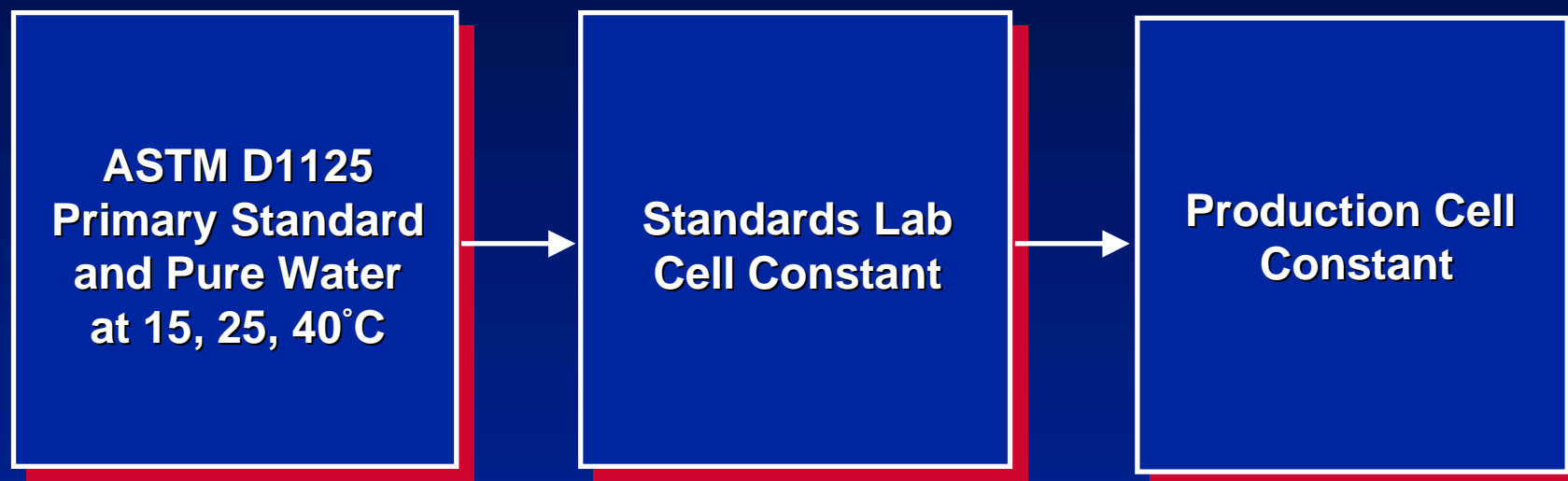
Industry Preferences:

Resistivity - Semiconductor ultrapure water

**Conductivity - Power, Pharmaceutical,
Pretreatment stages, Cooling towers,
Wastewater**

Total Dissolved Solids (ppm TDS)

Cell Constant Traceability



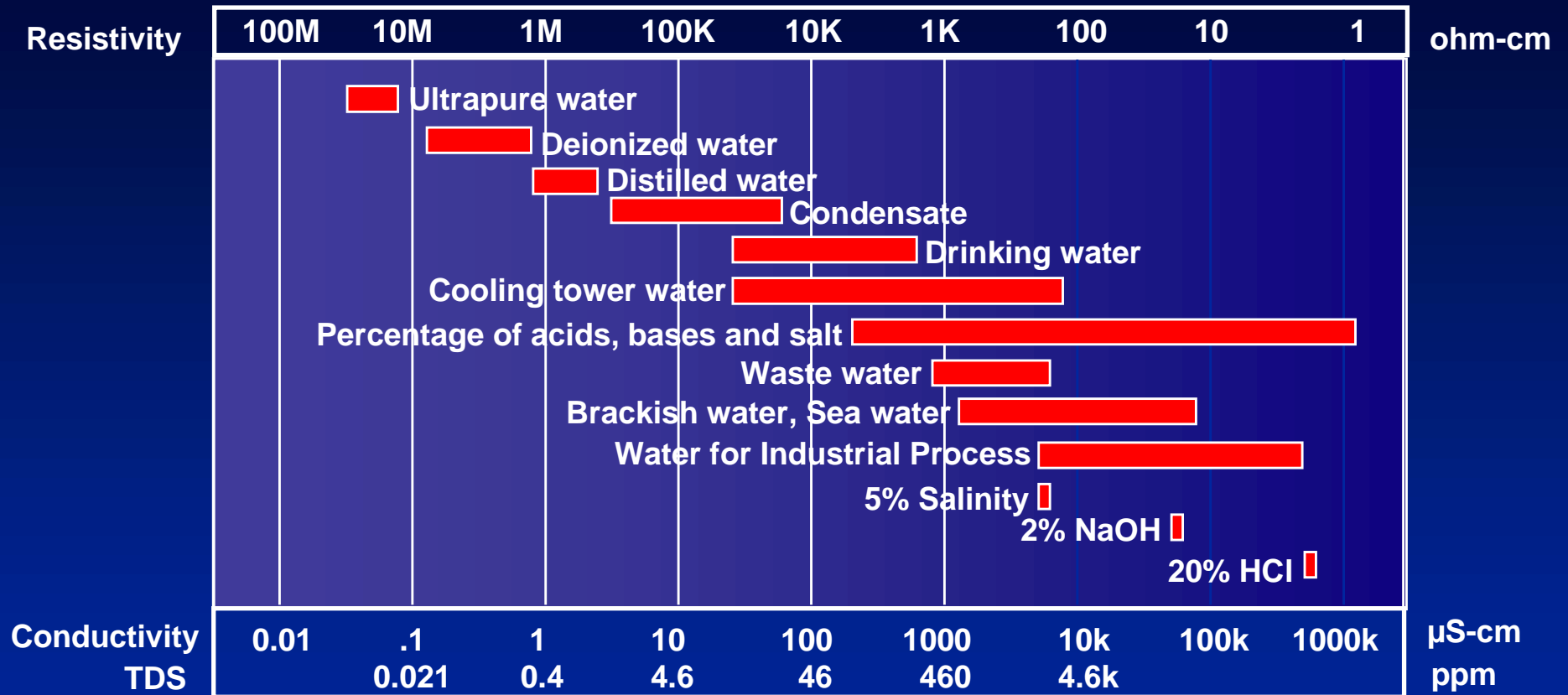
Ultrapure Water Sensor Calibration/ Certification System



Thornton Inc.

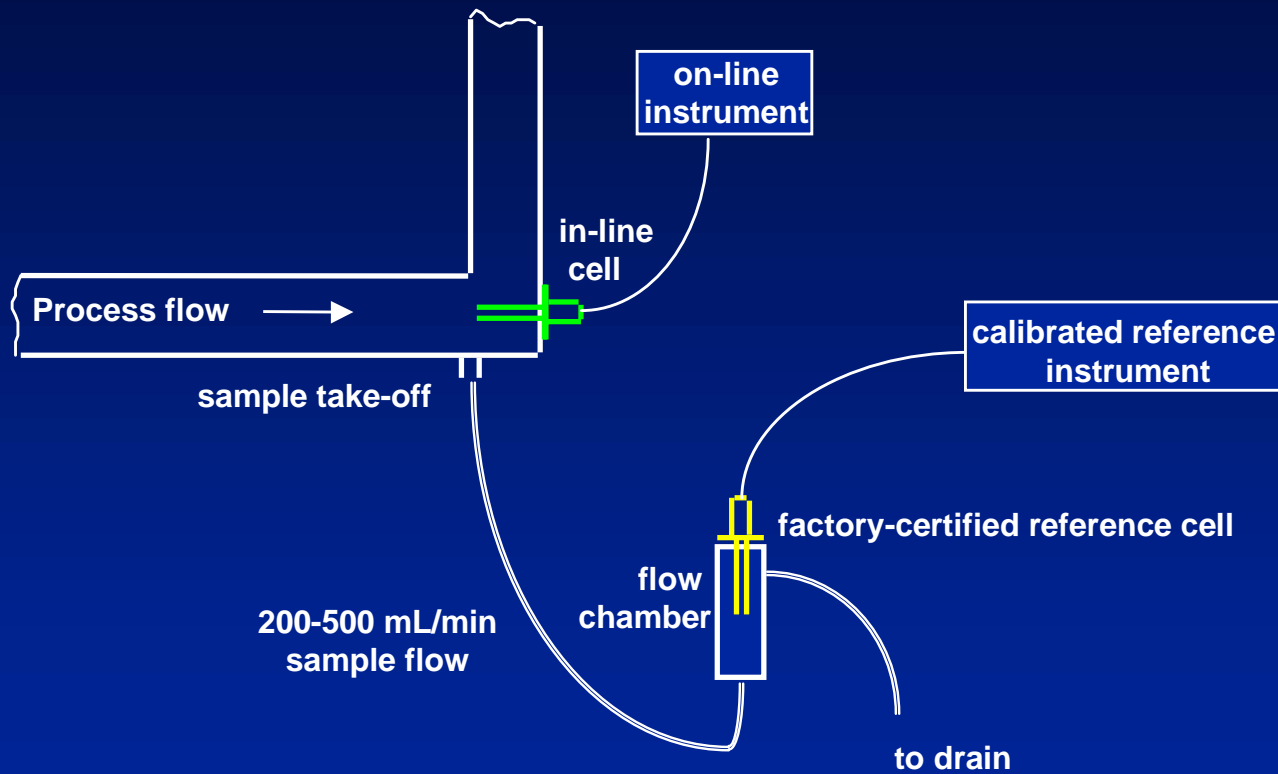
THORNTON / METTLER TOLEDO

Conductivity, Resistivity, TDS Ranges

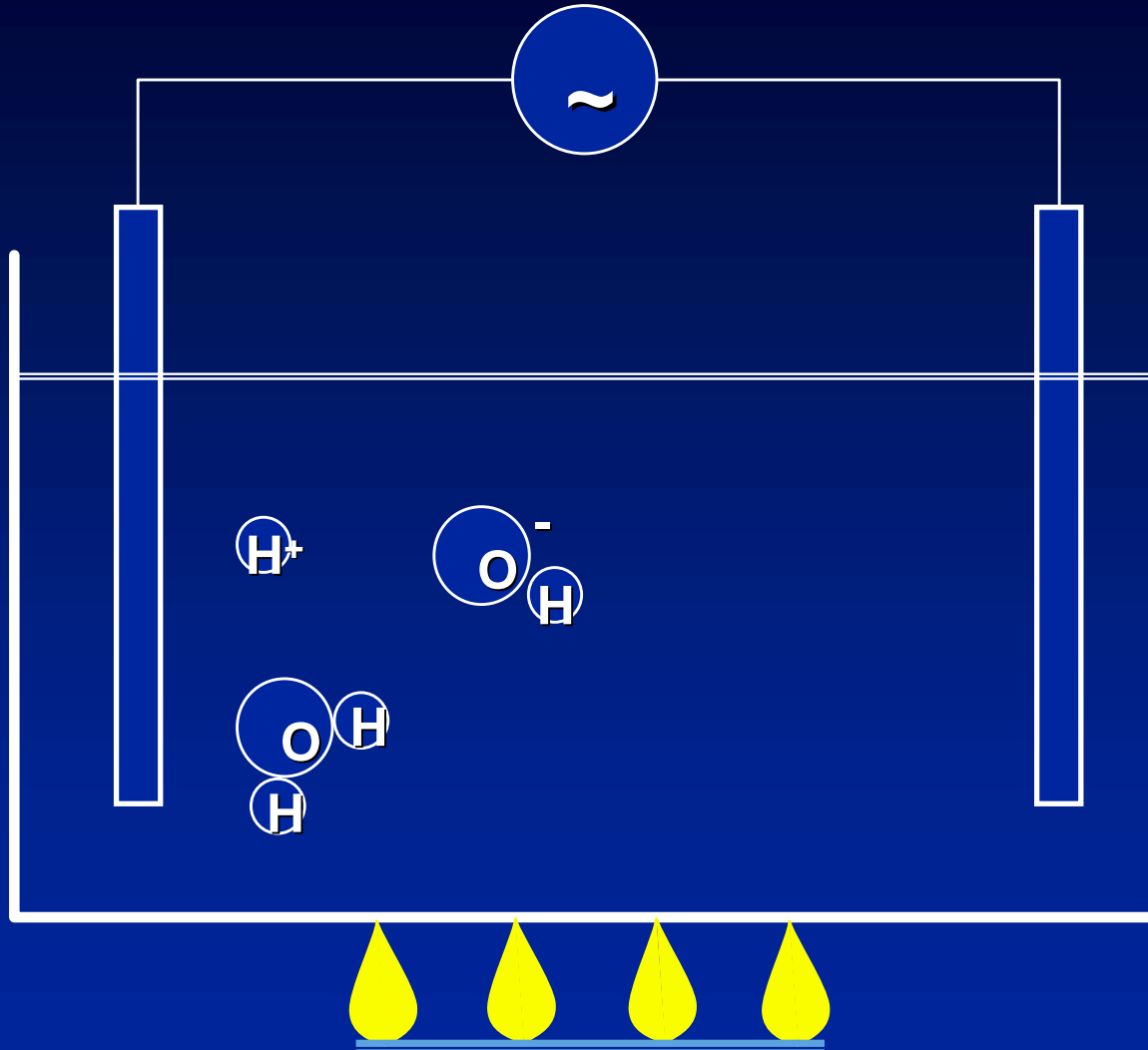


Conductivity and resistivity are measured at 25°C; TDS is expressed as Sodium Chloride (NaCl)

On-Line Conductivity Sensor Calibration/Verification



Temperature Effects on Conductivity





Conductivity/Resistivity Temperature Coefficients

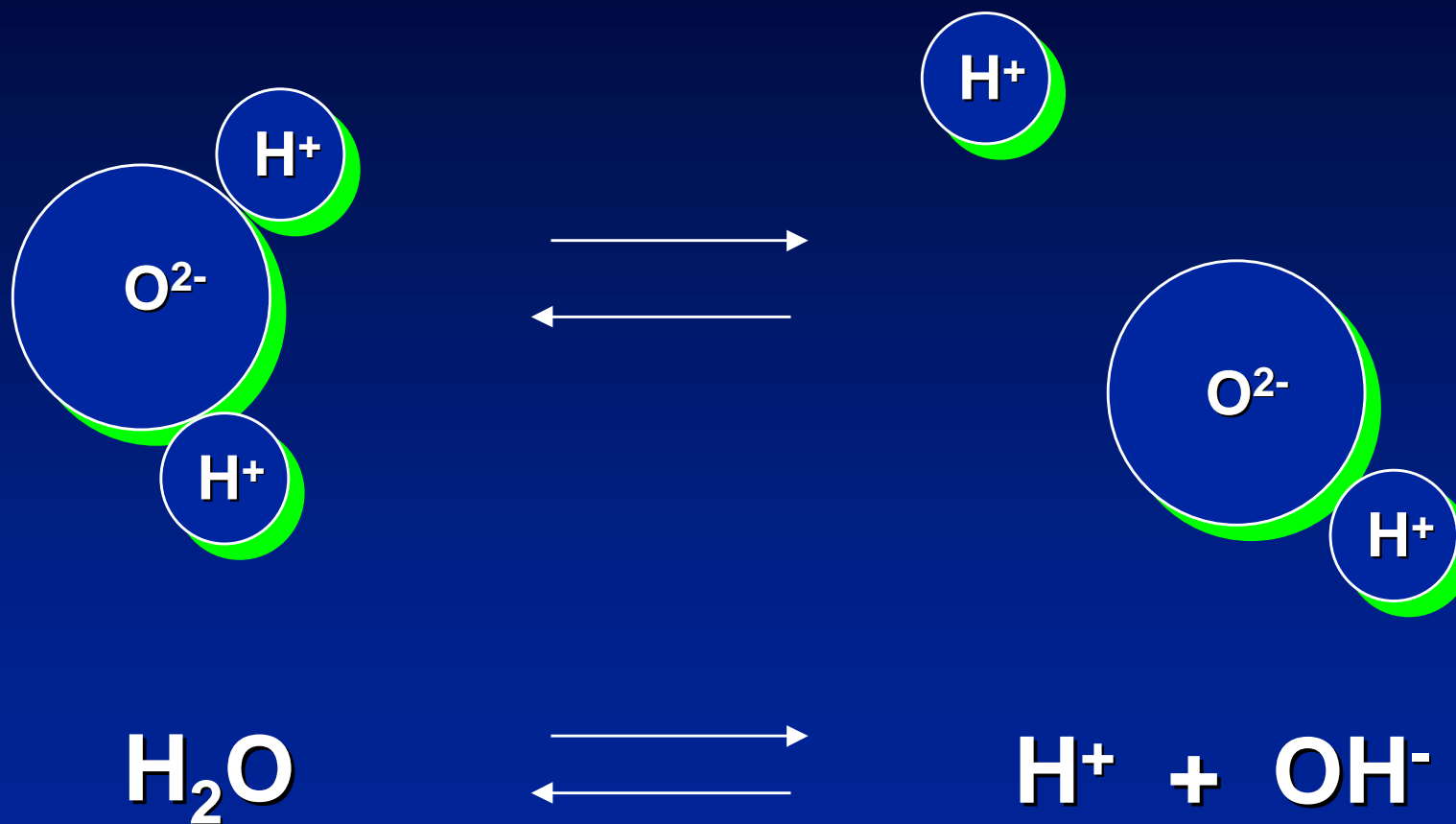
**Natural waters, etc.
($>2 \mu\text{S/cm}$)**

$\sim 2 \%/^{\circ}\text{C}$

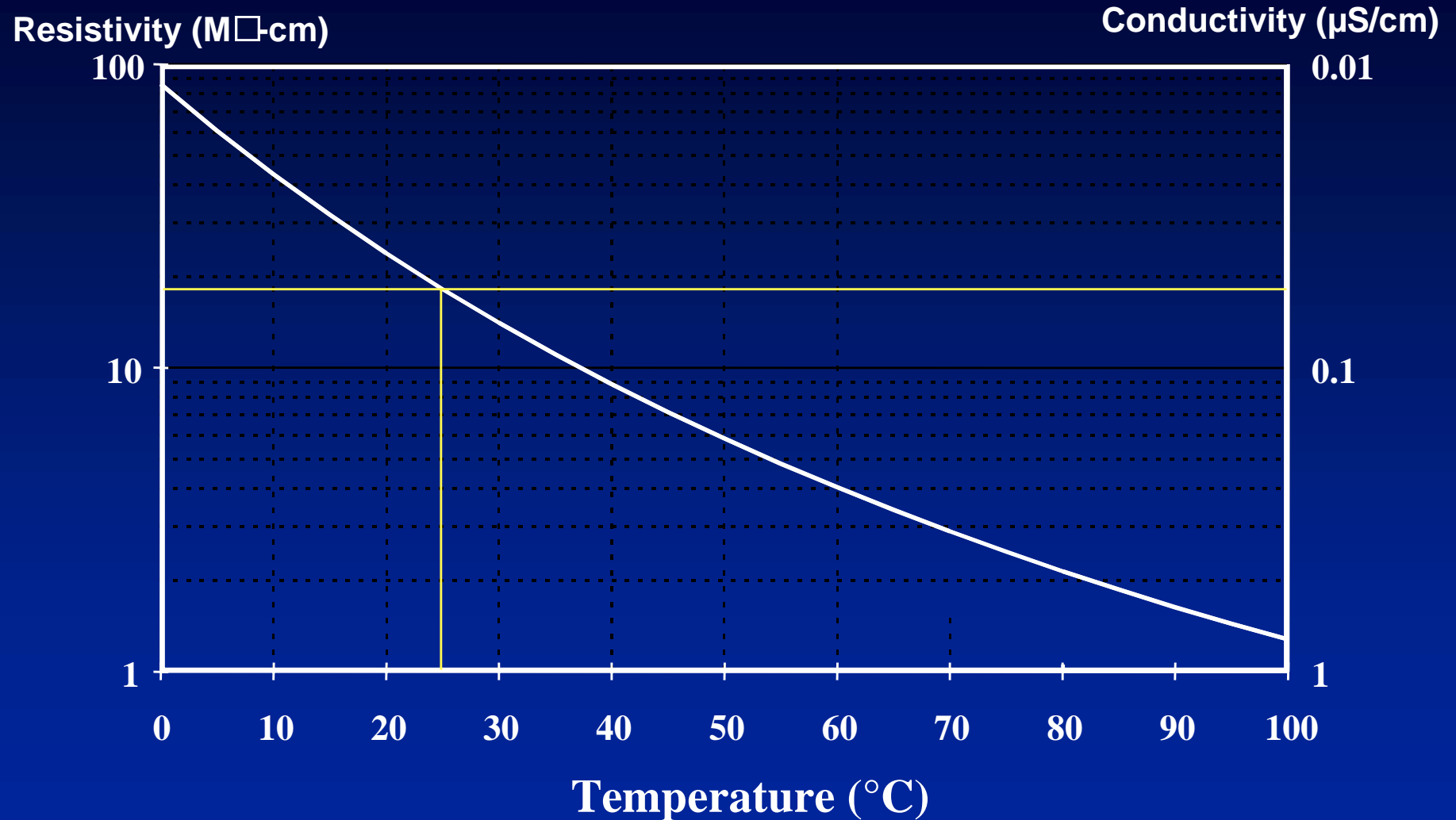
**High purity water
($0.055 \mu\text{S/cm}$ or 18.2 Megohm-cm)**

$4 - 7 \%/^{\circ}\text{C}$

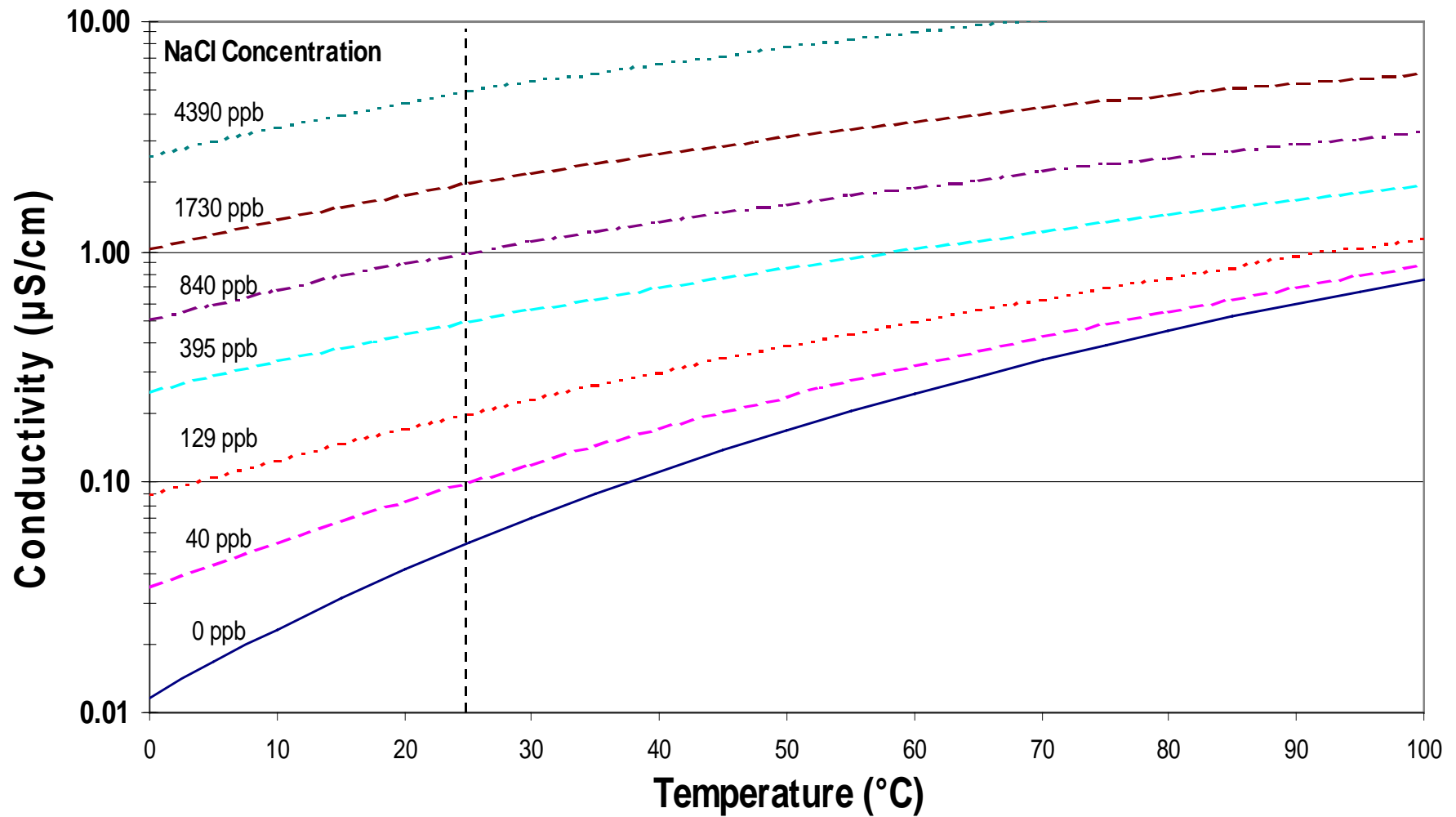
Dissociation of Water



Conductivity of Pure Water vs. Temperature



Conductivity vs. Temperature



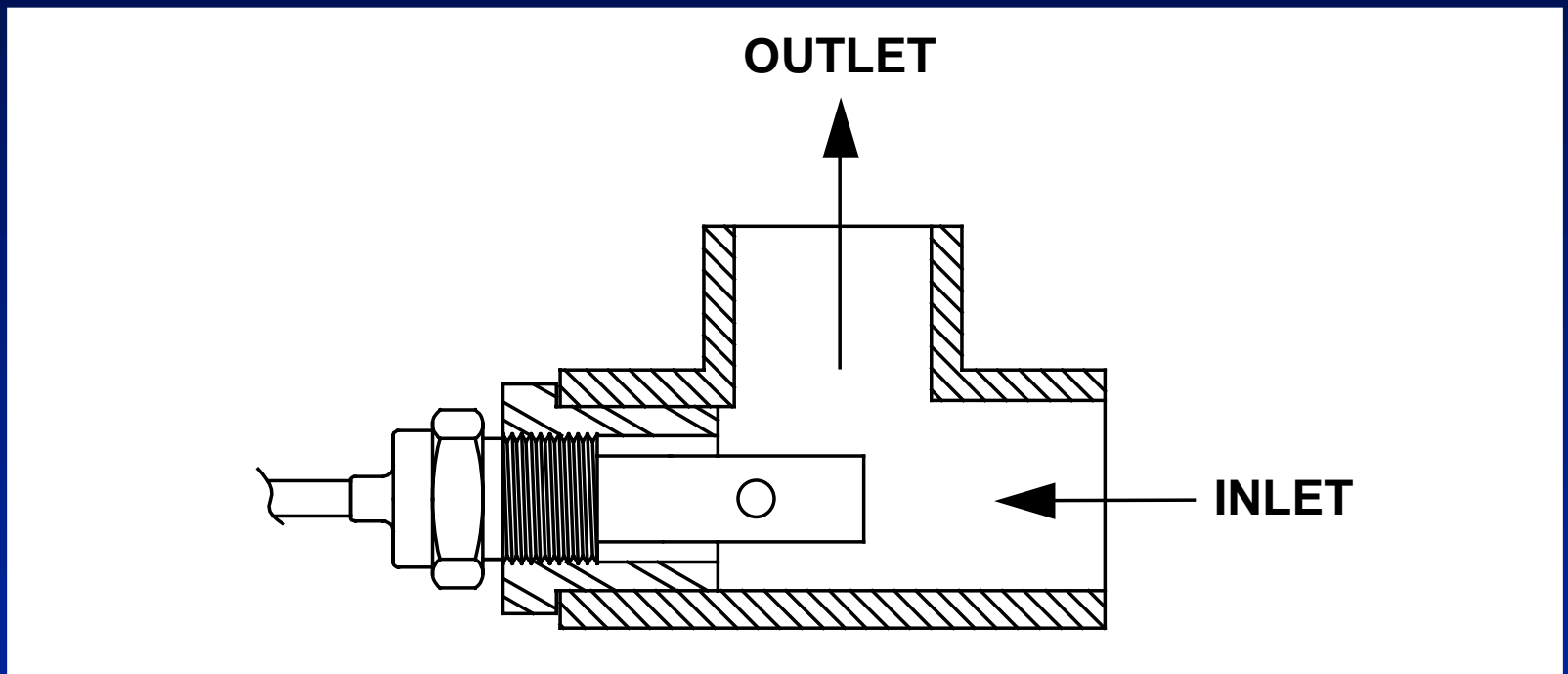


Temperature Compensation

- **Standard -- high purity water with mineral contamination**
- **Linear, %/°C -- special applications with known coefficient**
- **Cation/Ammonia/ETA -- power plant cycle chemistry and semiconductor acid etch rinse operations**
- **Alcohol -- special semiconductor rinse operations**
- **Glycol -- semiconductor coolant monitoring**
- **Light 84 -- same as Standard but with 1984 pure water data (reads slightly higher resistivity)**
- **Direct % Concentration Readout of HCl, H₂SO₄, NaOH automatically selects appropriate compensation**

Cell Installation

Recommended Cell Installation...



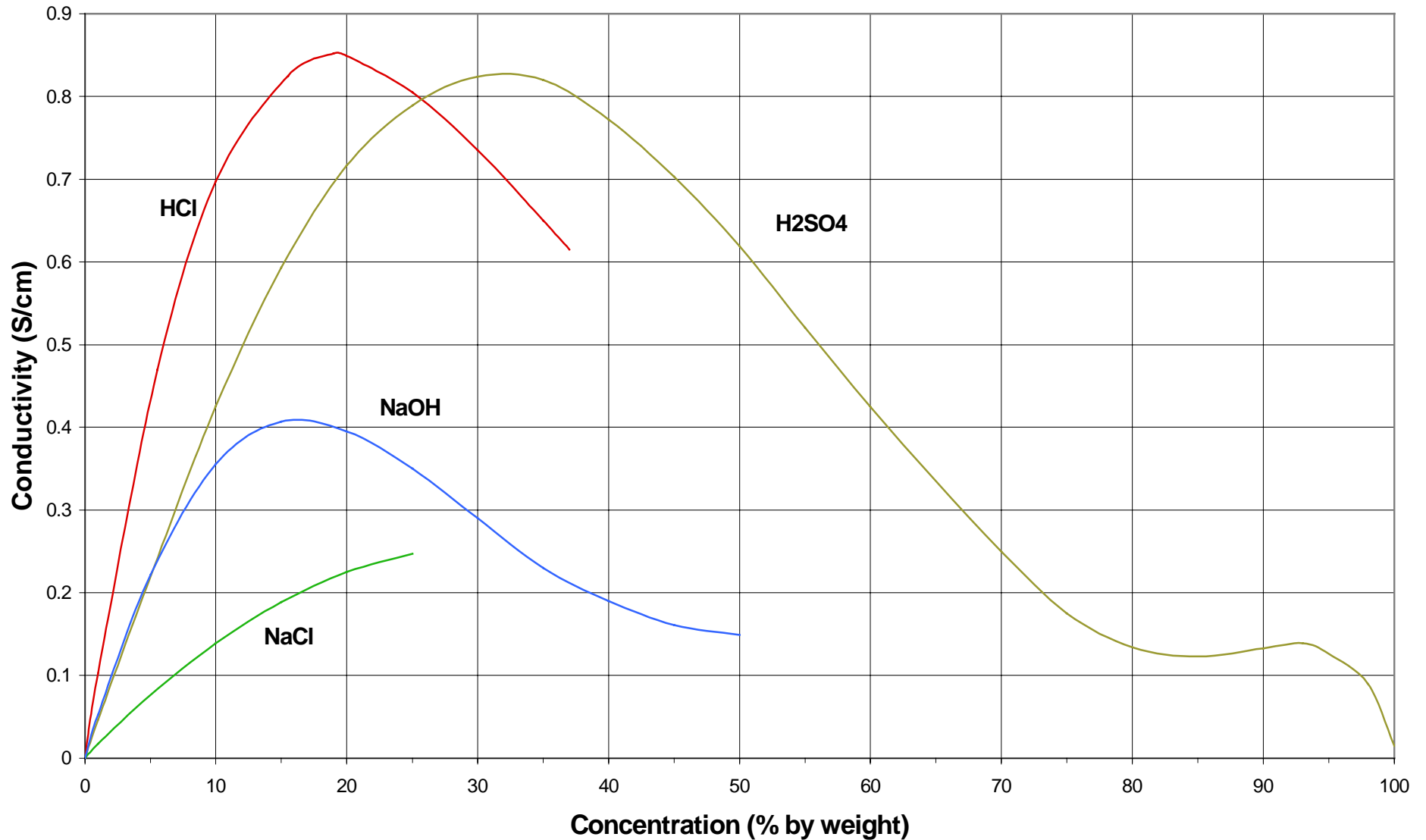
Flow should be directed at the end of the sensor



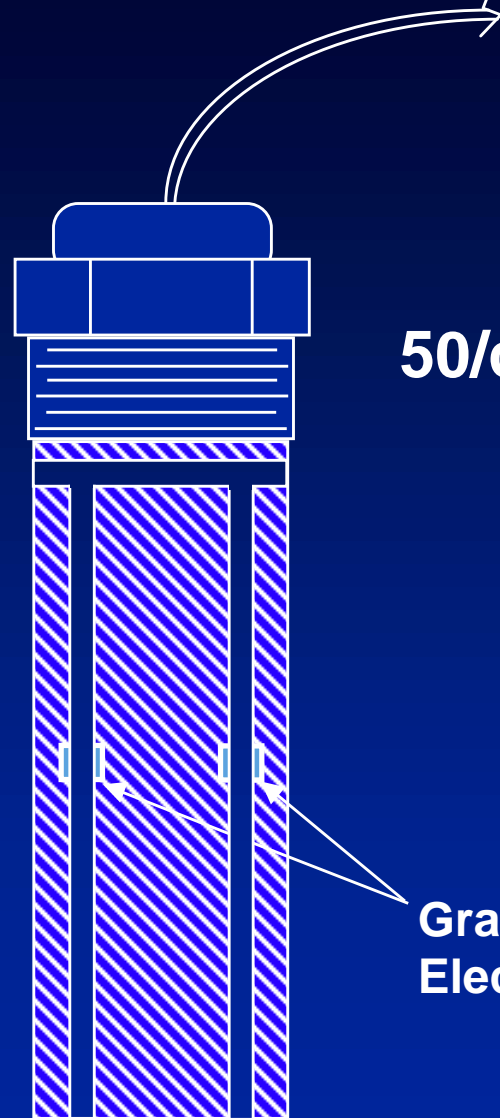
High Conductivity Measurements

- **Applications**
 - Reverse Osmosis feedwater
 - Acid/Base deionizer regenerant concentration
 - Process fluids
 - Recycle water
 - Wastewater/effluent
 - Cooling towers
- **Conductivity Measurement Technologies**
 - Two-electrode contact
 - Four-electrode contact
 - Inductive (non-contact, electrodeless, toroidal)

Conductivity vs. Concentration

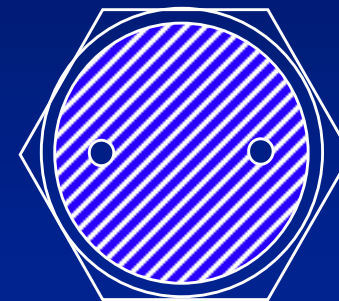


Two-Electrode Conductivity Measurement



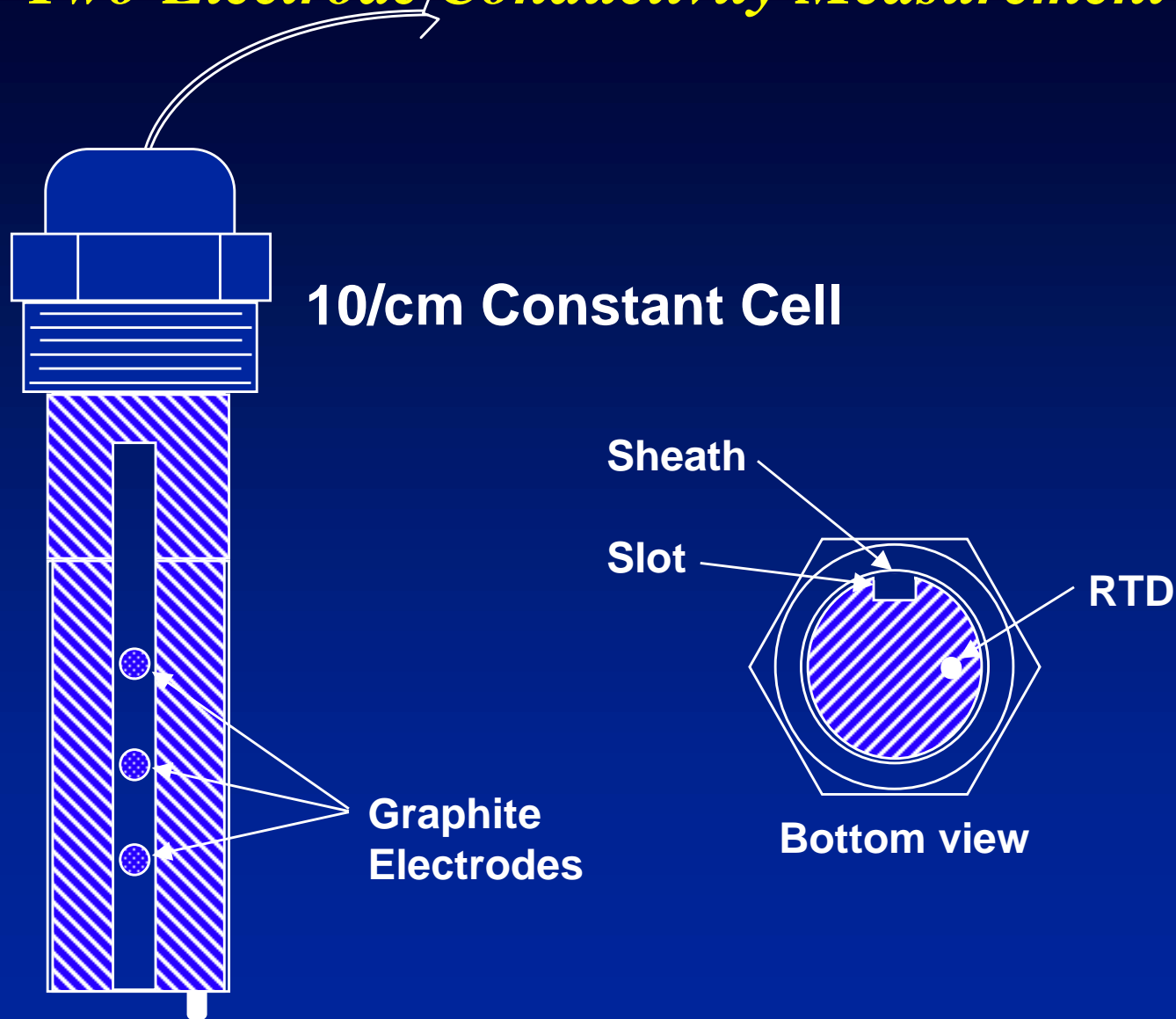
50/cm Constant Cell

**Graphite
Electrodes**

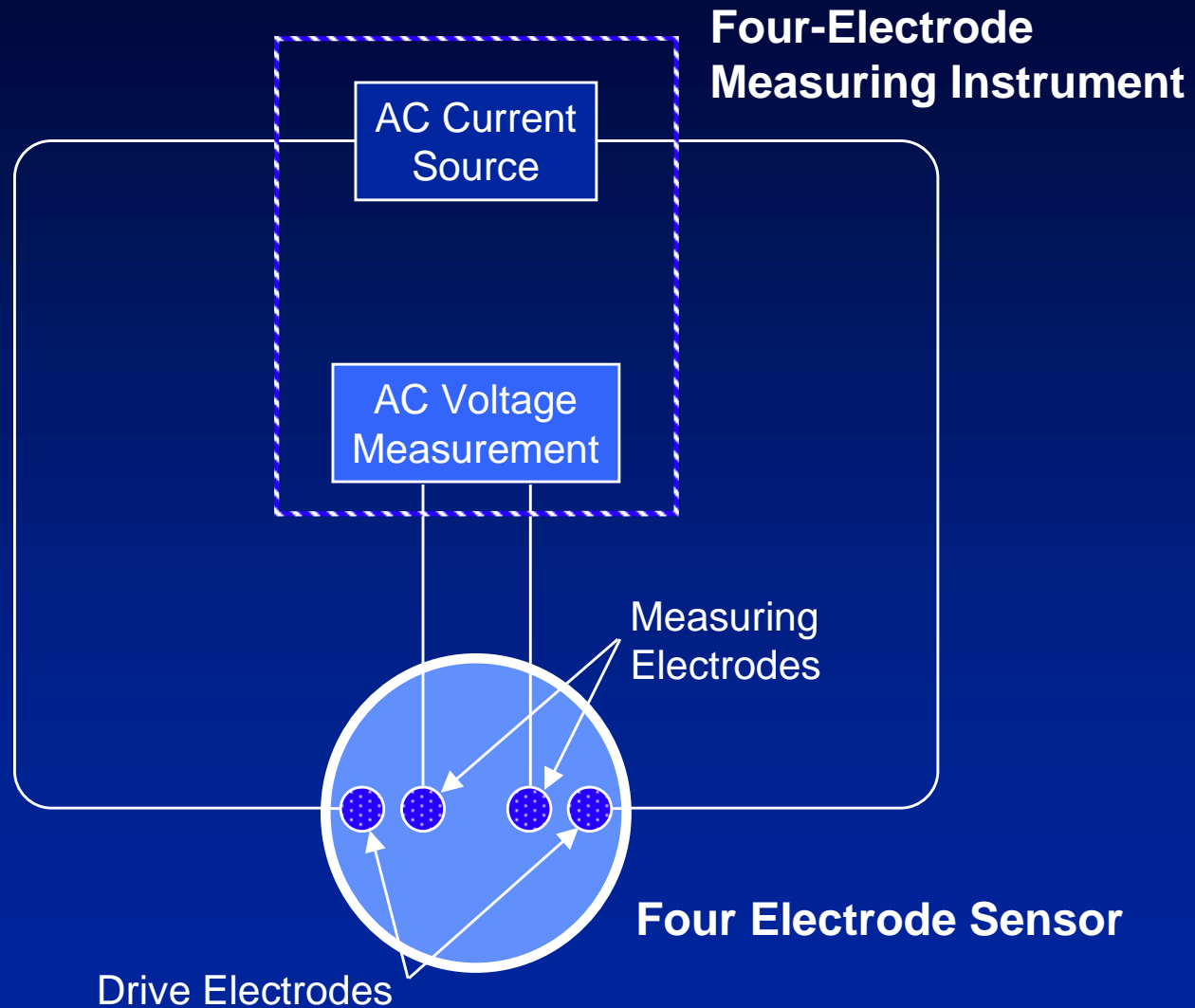


Bottom view

Two-Electrode Conductivity Measurement



Four-Electrode Conductivity Measurement



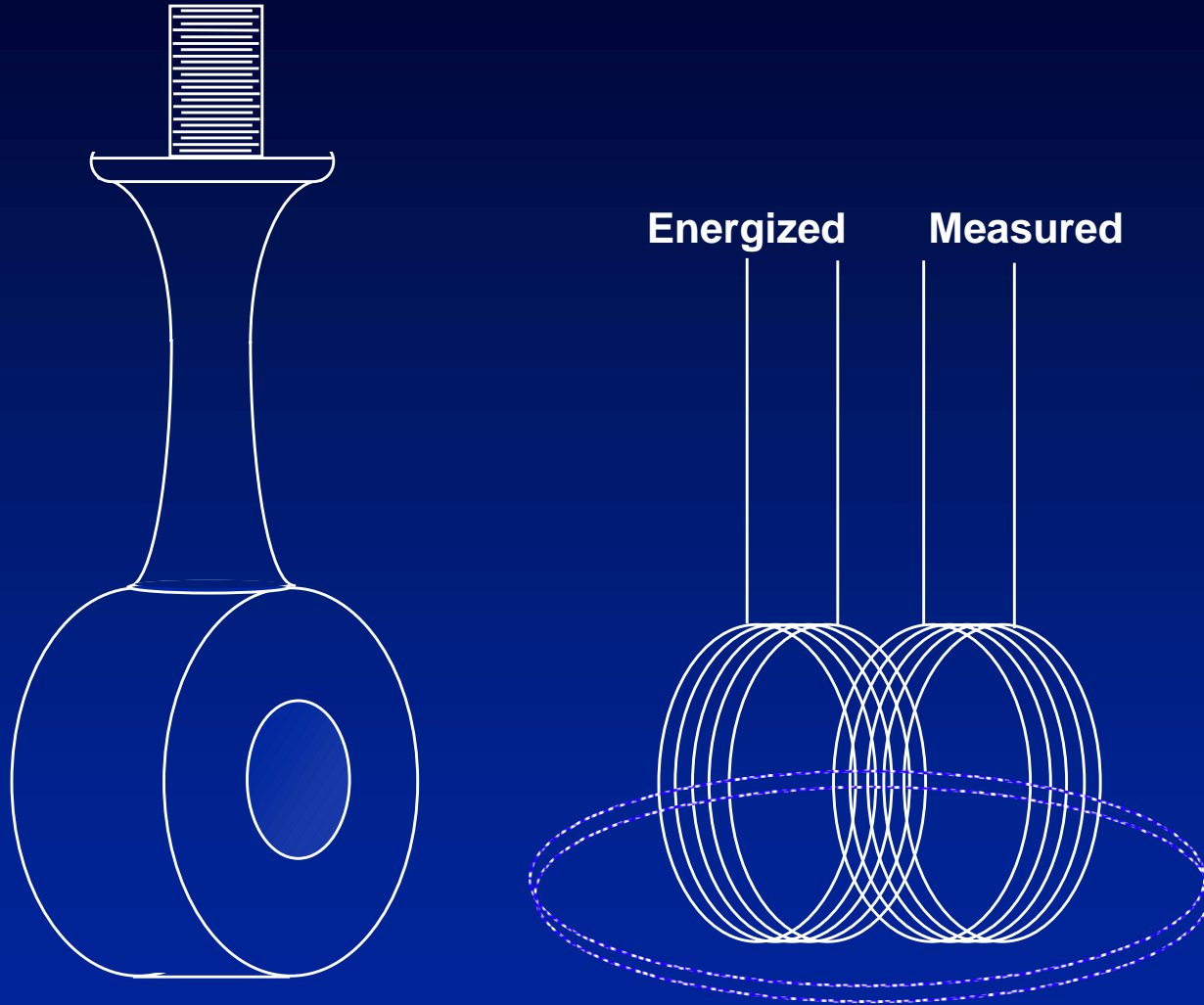
Four-Electrode Conductivity Measurement

Four-electrode sensors and instruments can tolerate poor measuring conditions due to three factors:

- 1. Electrode metal surface condition is less important.**
- 2. Electrode fouling or coating has much less effect.**
- 3. Four-electrode sensors do not have the narrow channels of high, two-electrode cell constants. The resulting flat surface design is much less vulnerable to fouling.**



Inductive Conductivity Measurement



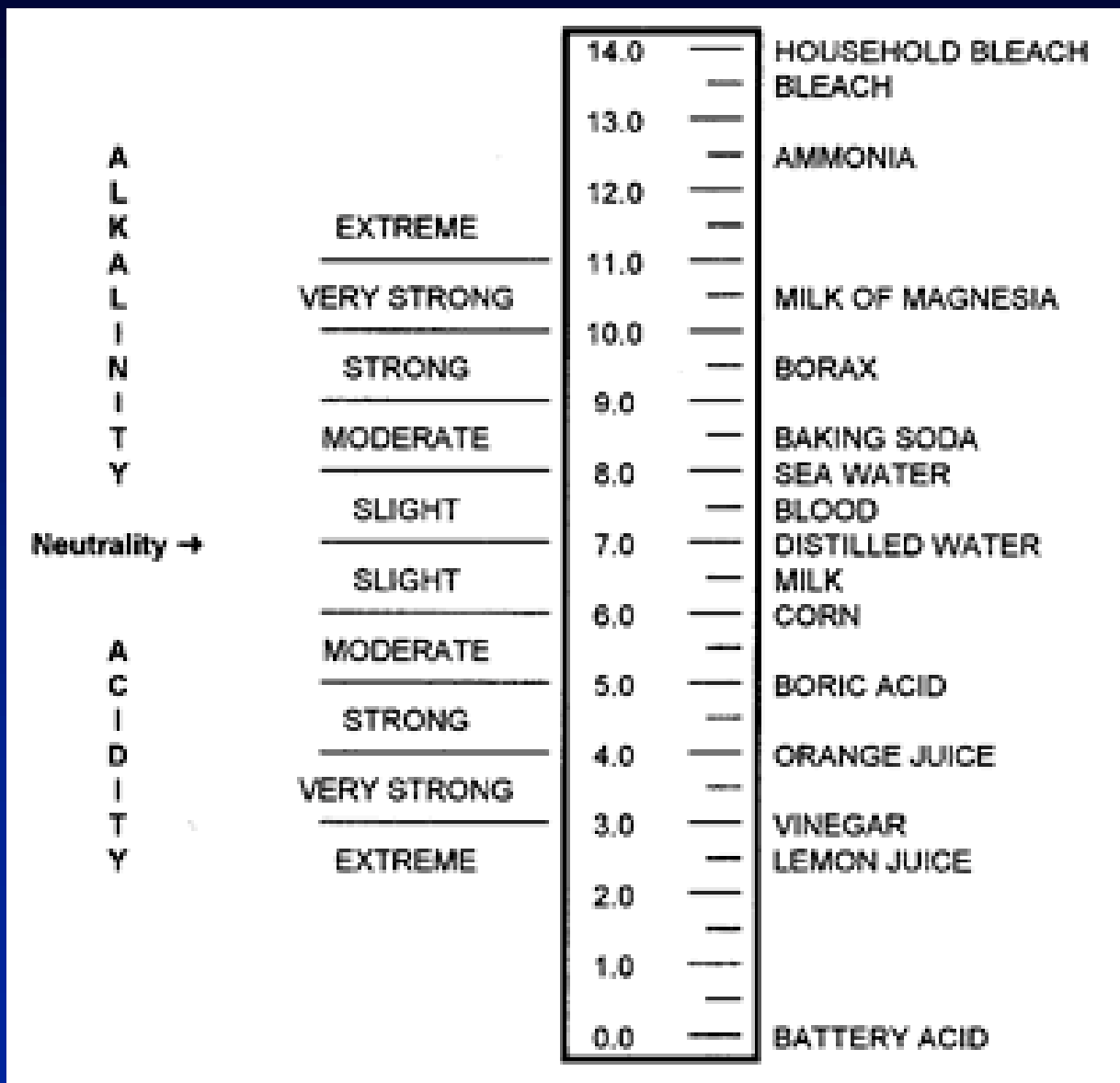
Inductive (non-contact, electrodeless, toroidal) Conductivity Sensor

Inductive Conductivity Measurement

- Virtually non-fouling
- No metal/solution contact
- Reliable high conductivity measurements
- Relatively large sensor size
- Cell constant can be affected by surrounding pipe



pH Range





pH Measurement

Dissociation of water



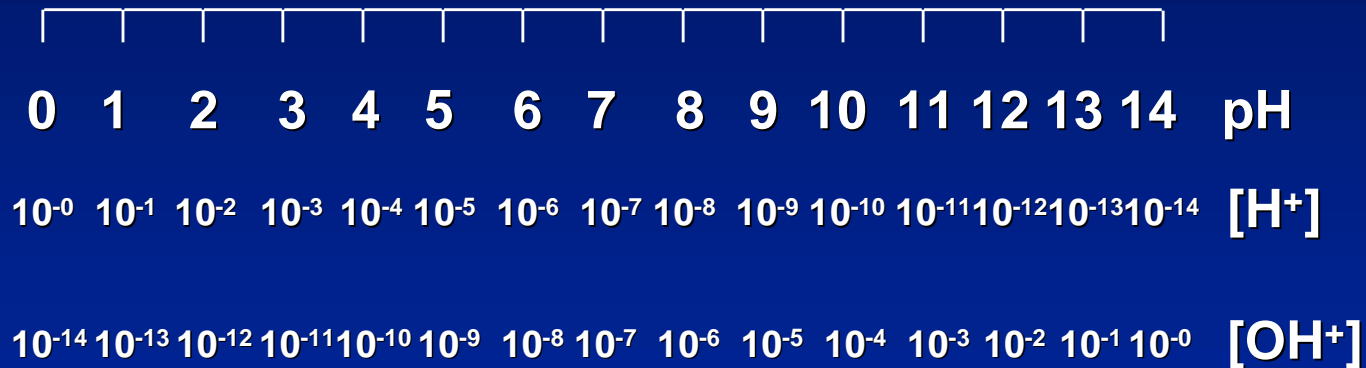
$$K_w = [\text{H}^+] [\text{OH}^-]$$



pH Scale

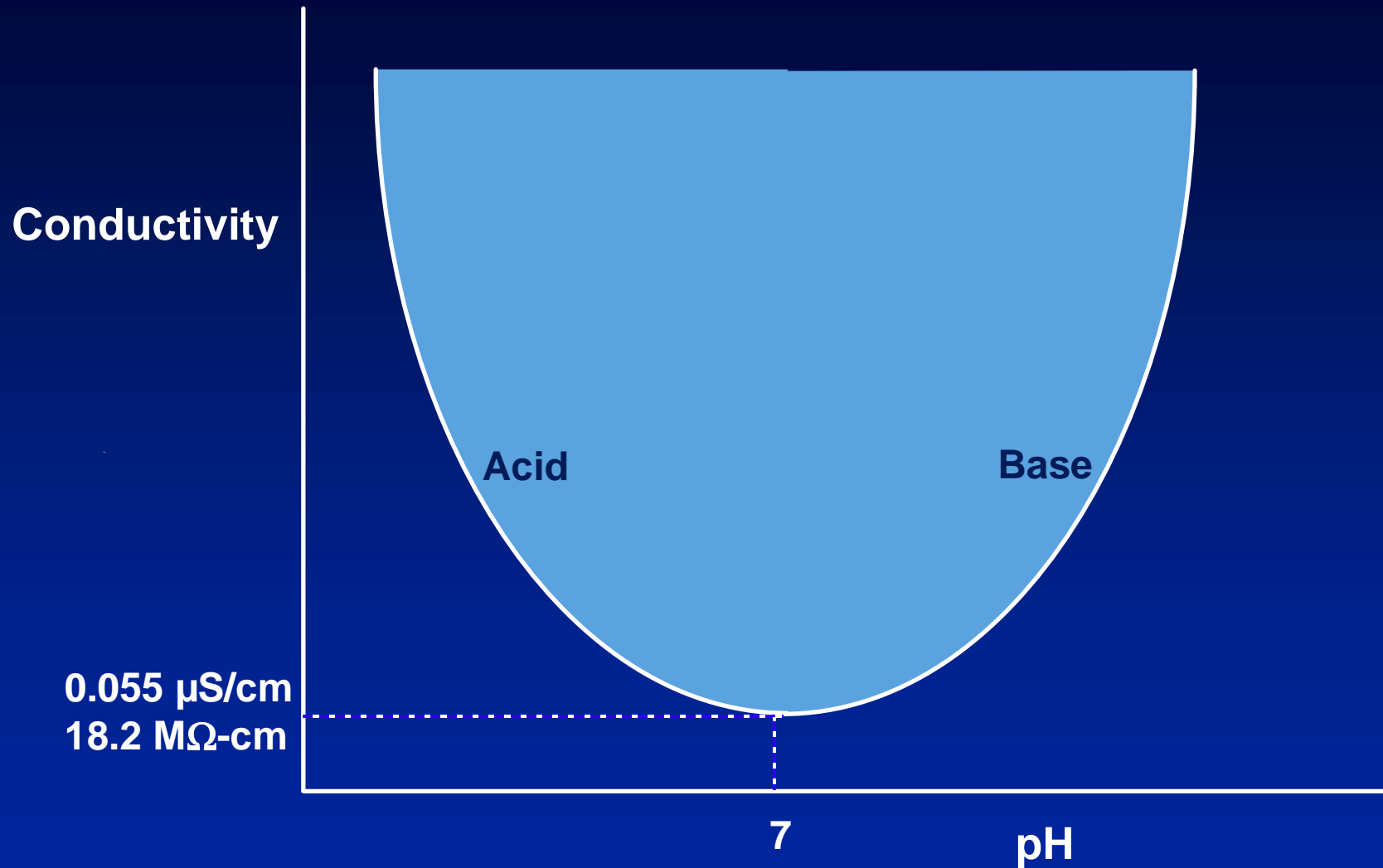
$$\text{pH} \sim -\log_{10} [\text{H}^+]$$

$$[\text{H}^+] \sim 10^{-\text{pH}}$$

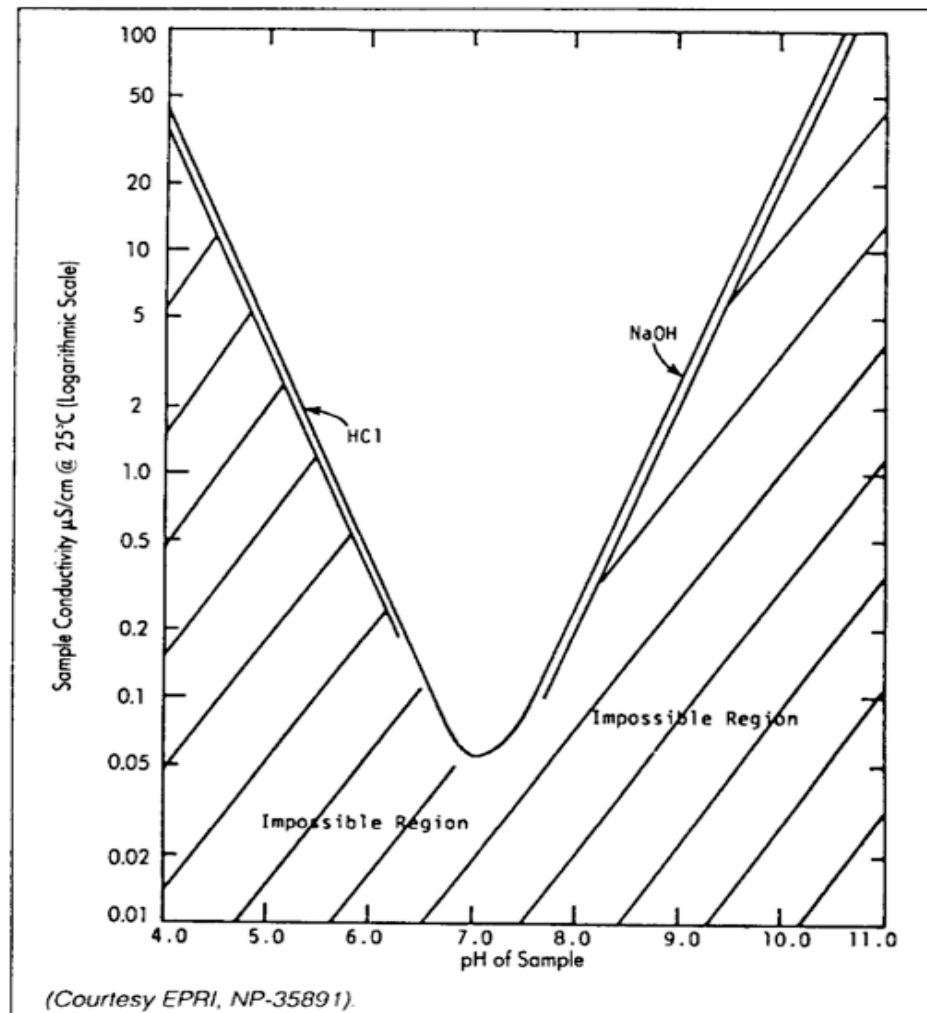


at 25°C

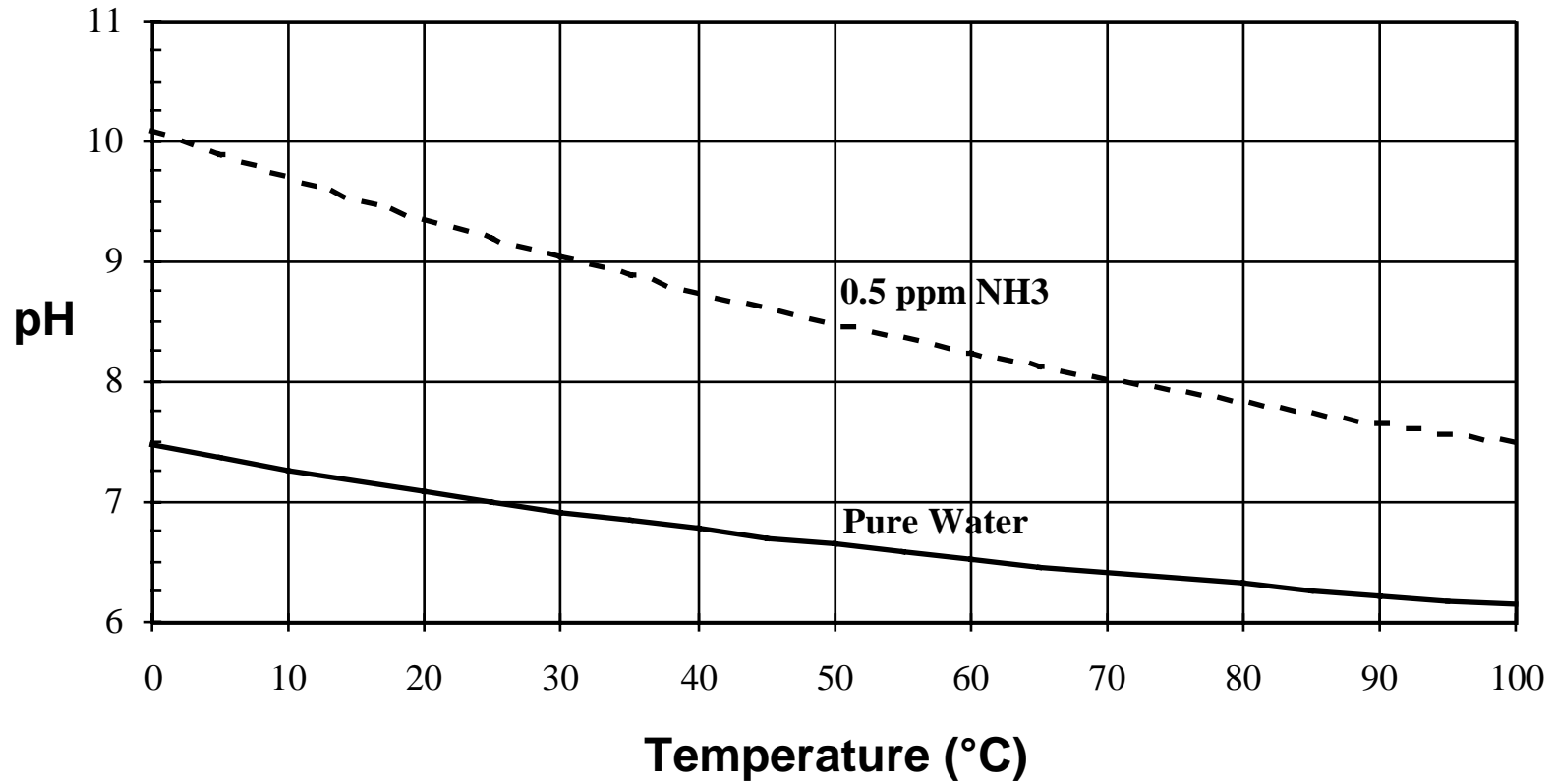
Conductivity vs pH



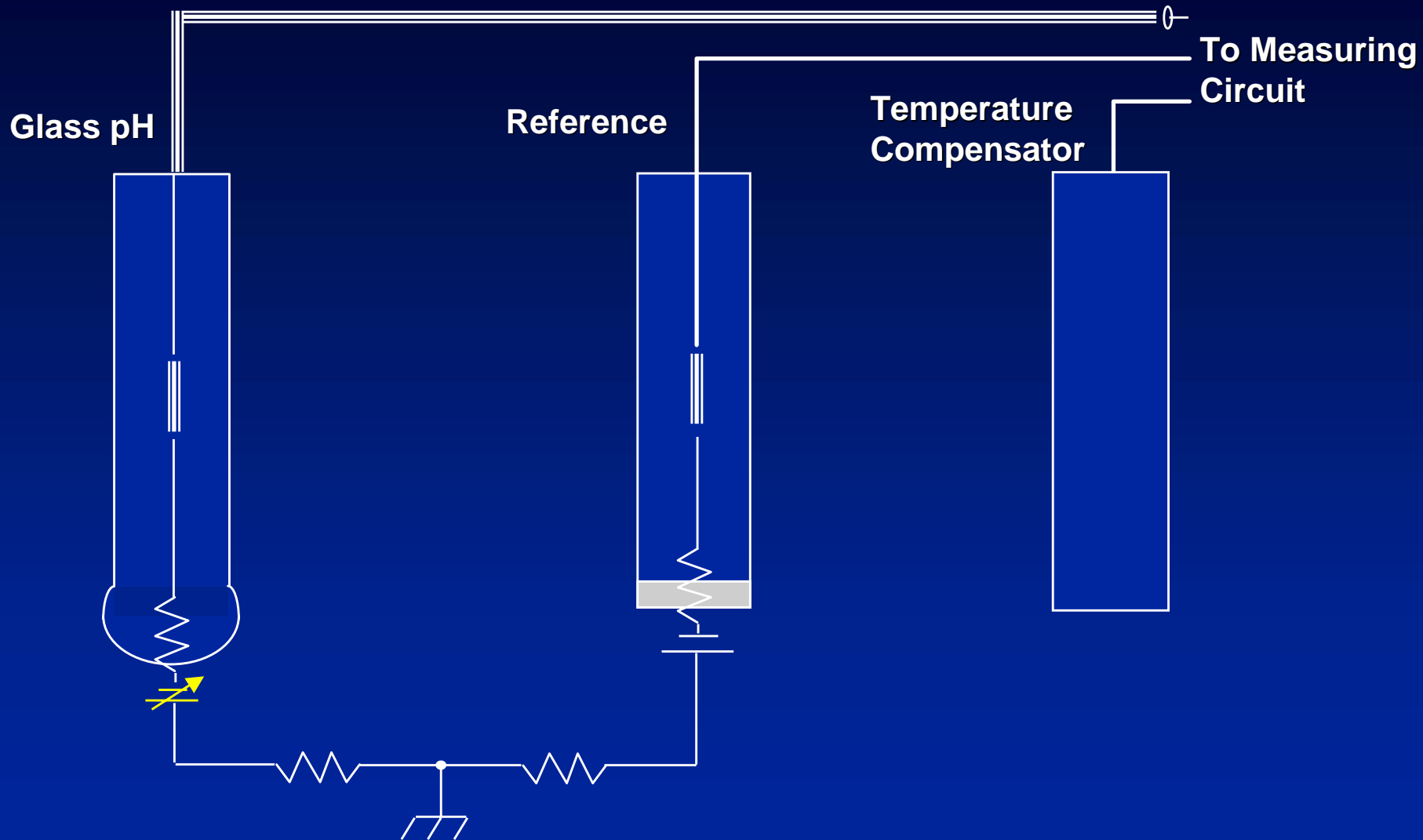
Conductivity vs pH



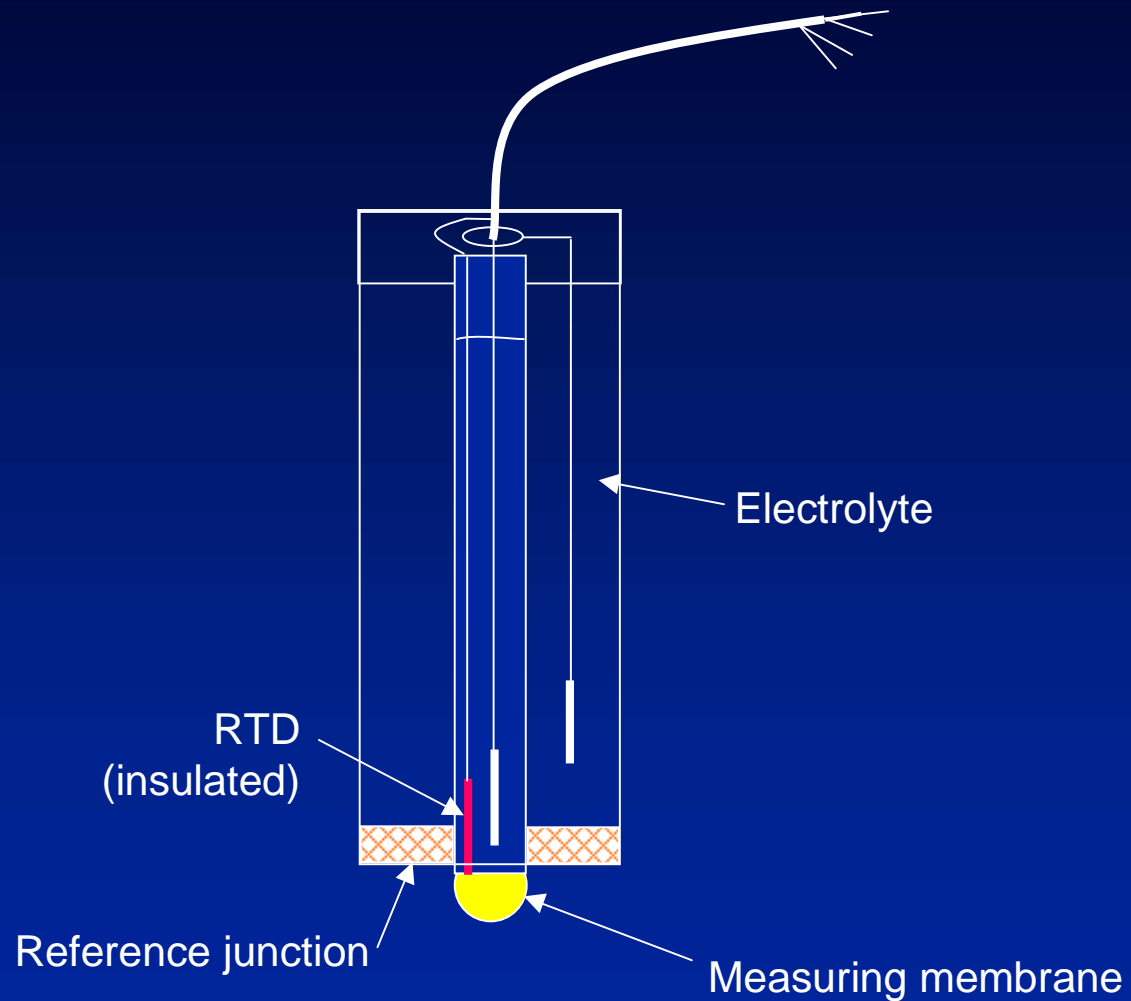
pH vs. Temperature for Pure Waters



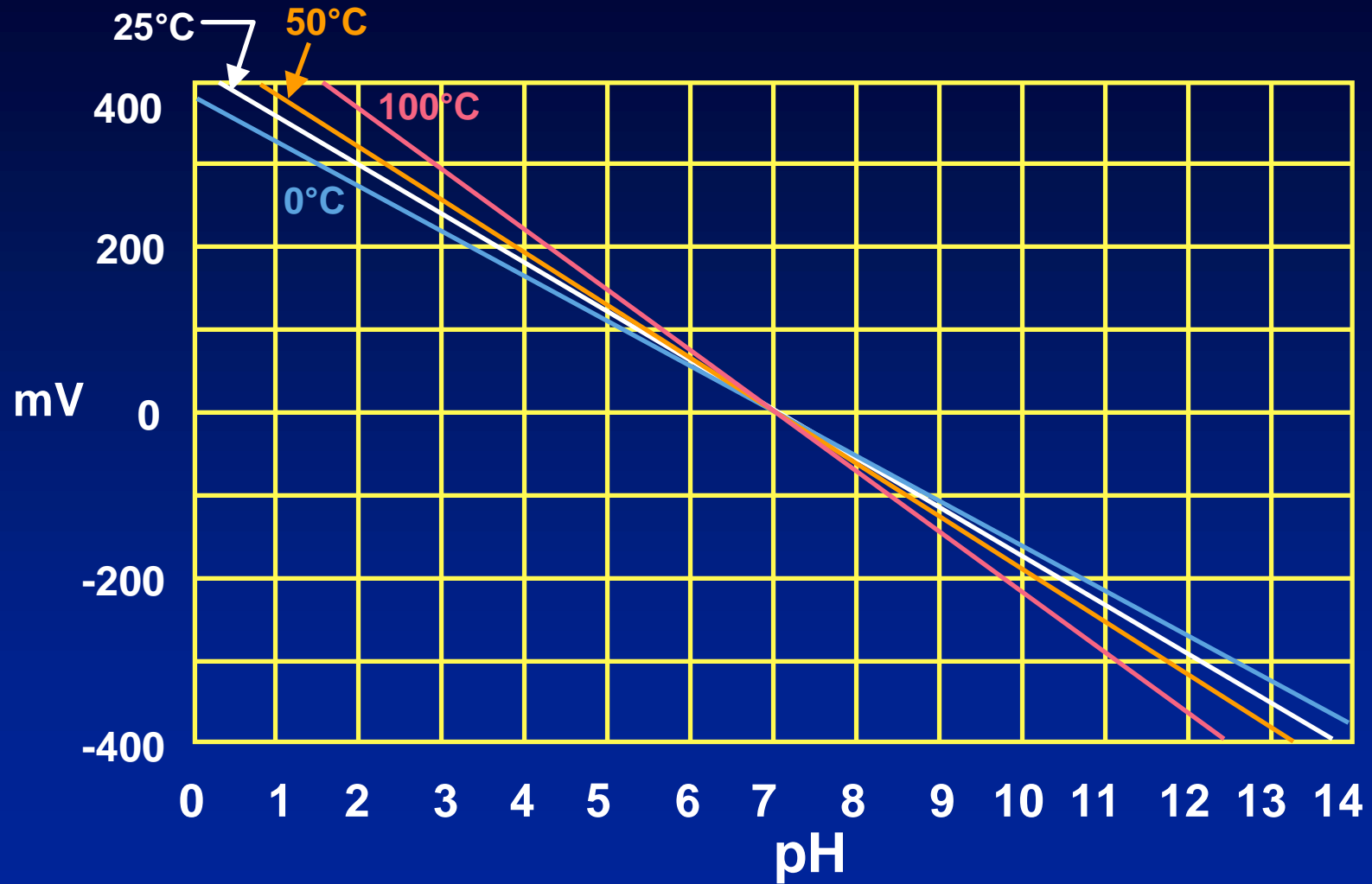
pH Electrode System



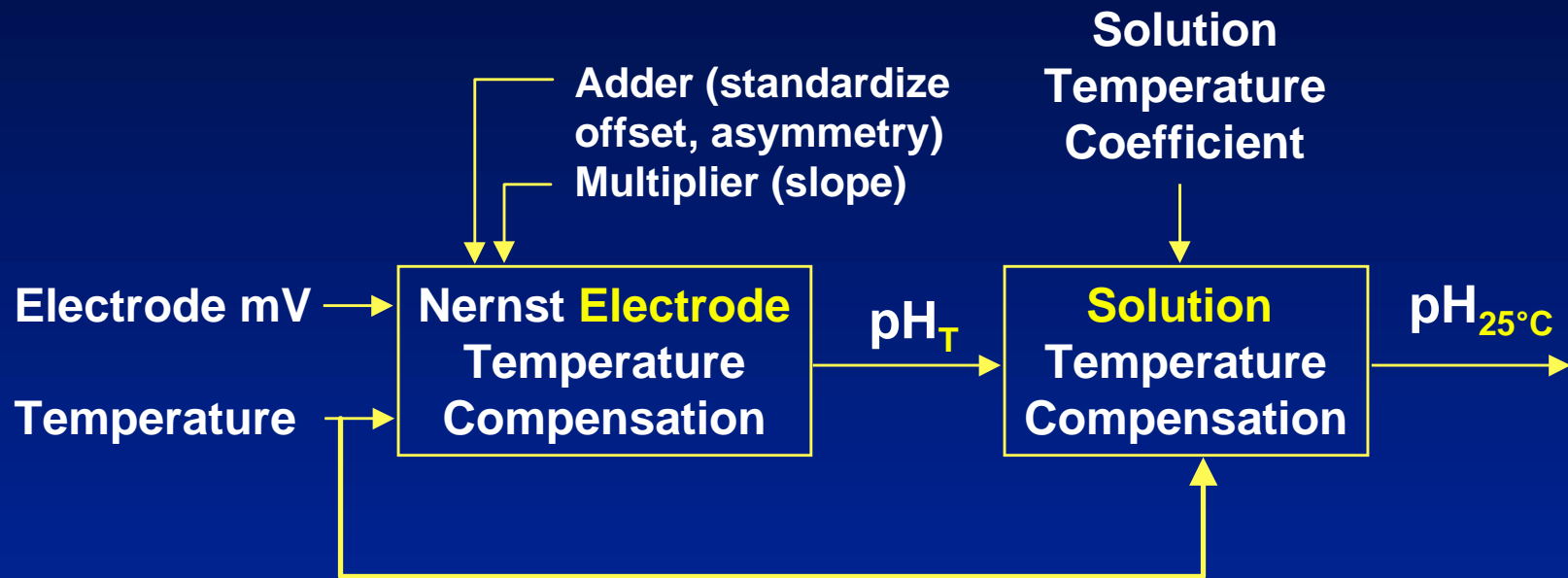
Combination pH Electrode



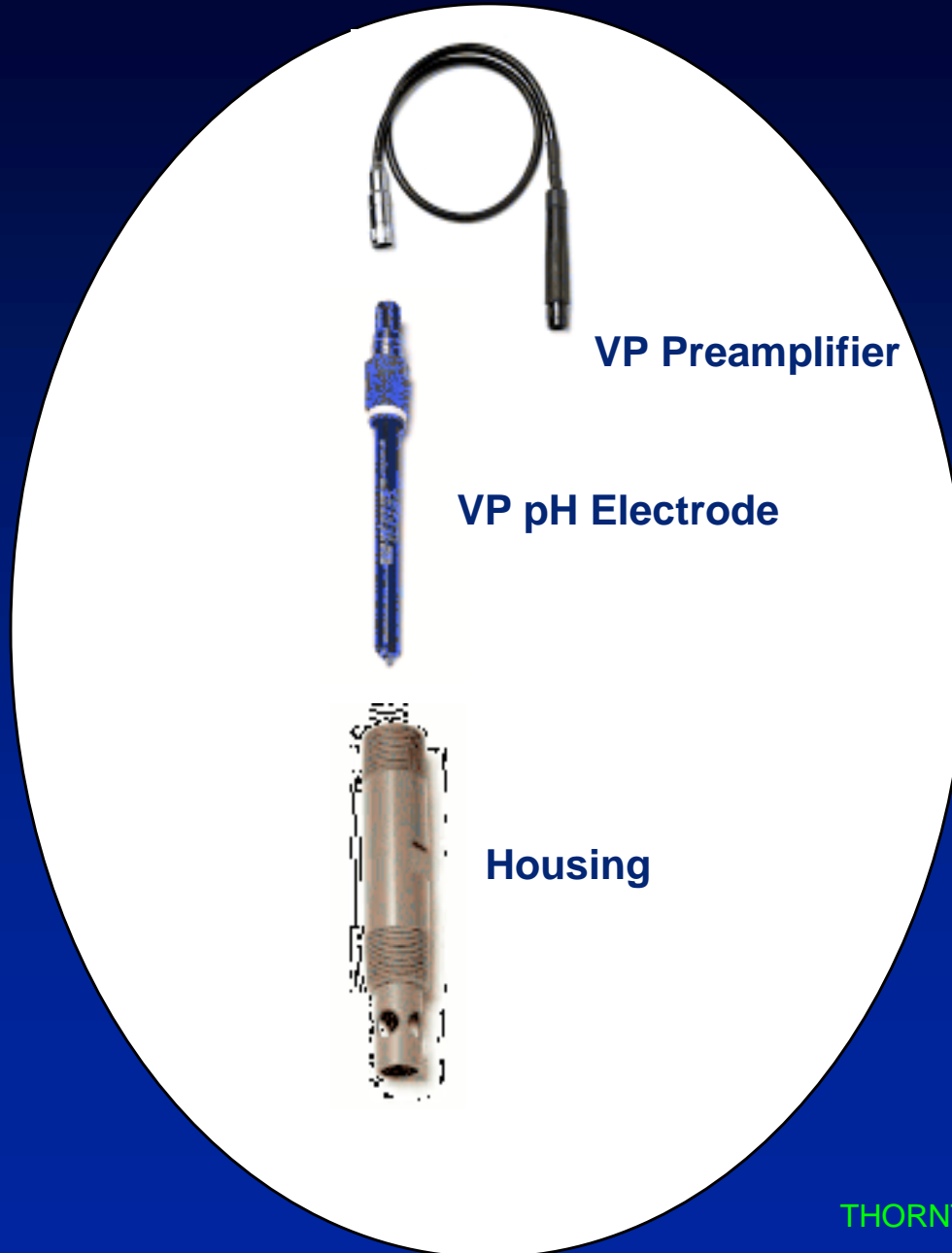
pH Electrode Output



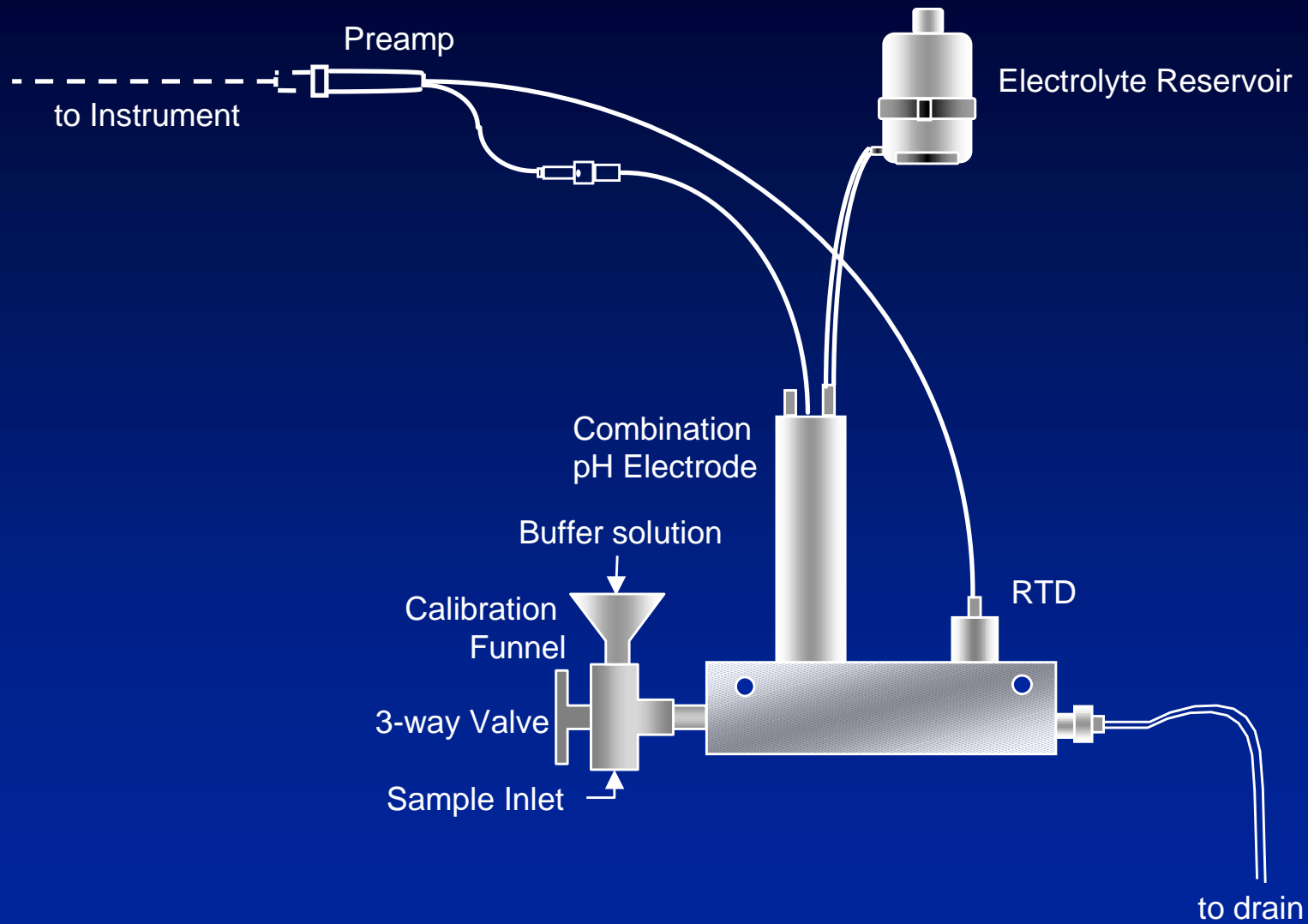
pH Temperature Compensation



Detachable pH Electrode System



High Purity pH Sensor Assembly





pH Standards

- **NIST standards--materials to make up buffers at: 1.681, 3.557, 4.006, 6.863, 7.41, 9.180, 10.011, 12.46 pH**
- **Commercial standard buffer solutions**
 - NIST recipes
 - Integral pH values
- **Have unique temperature dependence**



High Purity pH Measurement Equipment

- Low volume, stainless steel flow chamber
- Low sample flowrate with atmospheric discharge
- Flowing junction reference electrode
- *Solution* temperature compensation as well as *electrode* temperature compensation
- Convenient disabling of Solution temperature compensation during buffer calibration
- NIST-traceable buffer solutions



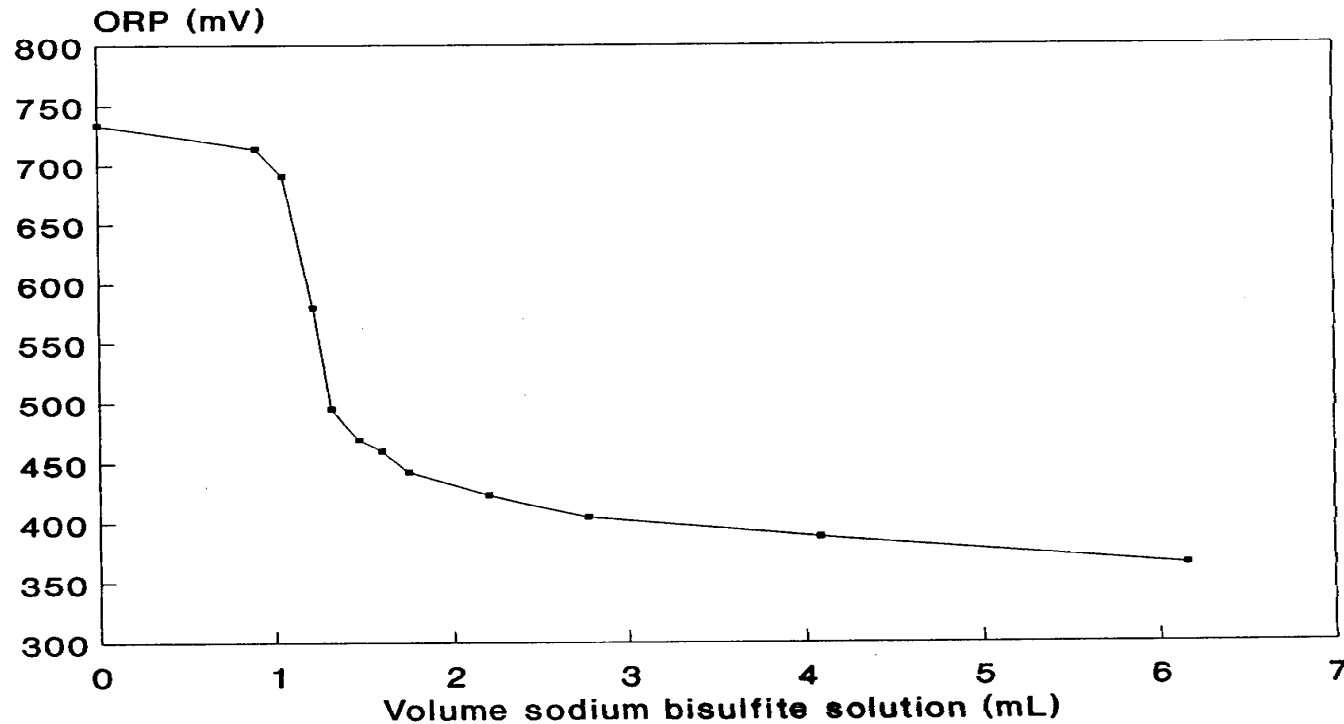
ORP:

Oxidation-Reduction (redox) Potential

- **Oxidation-reduction chemical reactions**
 - Oxidation—loss of electrons, higher potential
 - Reduction—gain of electrons, reduced potential
- **Examples**
 - Chlorine, ozone, permanganate can oxidize organics (color, odor, bacteria)
 - Bisulfite or carbon beds can reduce chlorine (protect RO membranes & DI resins); Hydrazine can reduce oxygen
- **ORP monitors the status of these reactions**

ORP Response to Dechlorination

Dechlorination ORP Titration
Sulfite Addition to Chlorinated Water



ORP Electrode System

